G.Collazuol on behalf of the T2K/ND280 collaboration Department of Physics and Astronomy University of Padova and INFN <u>NuFact 2024</u> <u>The 25th International Workshop on Neutrinos from Accelerators</u> Sep 16 – 22 2024 - Argonne National Laboratory

#### Technical challenges for the new T2K High Angle TPCs

#### **Overview**

- Introduction
- Highlights TPC Field Cages
- Highlights TPC Resistive MicroMegas
- Preliminary performances and conclusions









# The T2K experiment

Neutrino oscillation measurements → See talks by Ed Atkin and Tristan Doyle Neutrino cross-sections → See talk by Laura Munteanu



ND to measure un-oscillated beam flux and v cross sections

# ND280 upgrade New detectors to extend acceptance for tracks at high angles



# ND280 Upgrade new detectors





 \* New concept of detectors, 2x10<sup>6</sup> 1cm<sup>3</sup> cubes
 \* Each cube is read by 3 WLS → 3D view

Scintillator cube



New TPCs instrumented with Encapsulated Resistive Anode MicroMegas (ERAM)



#### TOF

6 TOF planes to reconstruct track direction Time resolution ~150 ps

### New detectors installation at JPARC

#### TOF installation (July 2023)





Bottom TPC installation (September 2023)





Super-FGD installation (October 2023)



# Commissioning with Cosmics in Nov '23



## **Early Neutrinos**

# Technical Run in Dec'23 and first neutrino beam run for Physics in Feb'24



# Near Detector ND280 $\rightarrow$ fully upgraded







# Beam Run for Physics - June 2024



# Neutrino interactions w/ high angle tracks



Event number : 387622 | Run number : 16847 | Spill : 33329 | Time : Fri 2024-06-07 20:10:30 JST | Trigger: Beam Spill



 Hid
 Top
 Actors

Event number : 409466 | Run number : 16847 | Spill : 35587 | Time : Fri 2024-06-07 21:02:42 JST | Trigger: Beam Spil



Event number : 409466 | Run number : 16847 | Spill : 35587 | Time : Fri 2024-06-07 21:02:42 JST | Trigger: Beam Spil

# Overview

# Highlights Field Cages

Mechanical - Building, assembly and characterization

Electrical - High Voltage Insulation and Electric Field

# Highlights ERAM sensors

Production of 50 sensros and Operations experiences

Detector response, signal and impact on reconstruction  $\rightarrow$  TPC performances

# **HATPC** specifications

Momentum resolution  $\sigma_p/p < 9\%$  at 1GeV/c (neutrino energy)

Energy resolution  $\sigma_{dE/dx}$ < 10% (PID muons and electrons)

Space resolution O(500 μm) (3D tracking & pattern recognition)

Low material budget walls ~ 3% X<sub>0</sub> (matching tracks from neutrino active target)



# Some HATPC features

Field Cages  $\rightarrow$  thin walls, lightweight, robust & compact

- $\rightarrow$  Thin walls, low Z, solid dielectric composite materials
- → Rectangular shape to minimize dead space & maximize tracking volume
- $\rightarrow$  Electric field uniformity better than 10<sup>-3</sup> @1cm from walls by

#### MicroMegas detectors

- $\rightarrow$  Encapsulated Resistive Anode MM (ERAM)
- $\rightarrow$  Charge spread: high spatial O(400µm) resolution with large pads O(cm<sup>2</sup>)
- → Intrinsic protection against sparks: simplified & very compact FE electronics

# Field Cages – constraints & adopted solutions

- Min dead space & max active volume in dipole magnet
  - → Rectangular shape & thinnest walls & field shaping electrodes incorporated into wall
- Electric field uniformity better than 10<sup>-3</sup> @1cm from walls
  - $\rightarrow$  Mechanical accuracy = inner surfaces planarity & parallelism ~ O(0.2mm/m)
  - $\rightarrow$  Electrode design = Field and Mirror copper strip layers on two sides of a Kapton foil
- Low material budget walls
  - $\rightarrow$  lightweight & lowest Z & robust & self supporting

Mechanical and Electric field constraints

-> Building process = hand lay-up of composite materials on a mould & polymerization in autoclave at high Pressure

- autoclave dimensions → Field Cage comprising two halves (symmetrical flanges at central cathode position)
- hand layup & large dimensions → several hours per process step → very long pot life epoxy resin
- mechanical accuracy of geometry → resin curing at low Temperature < O(40°C)</li>
- HV insulation mantle Resistance > 1TOhm and ... no HV discharges (Cathode potential ~ -30kV)
  - $\rightarrow$  geometry = several cm paths for charge from -HV strips to GND shielding (cathode flanges)
  - $\rightarrow$  insulating dielectric materials = very high resistivity & dielectric strength & lowest Z

Electrical Insulation constraints

#### $\rightarrow$ Materials of choice

- lamination materials = Aramid polymers for peels (Twaron) and for honeycomb (Nomex paper)
- epoxy resin = very limited choice of epoxy & very important quality control against contaminants (water, ...)
- high insulation layers = Kapton and lamination at low Temperature < 40°C (no use of Mylar)</li>
- box skeleton material = high quality laminated isotropic G10

# **Highlights Field Cages**



Mechanical - Building, assembly and characterization

Electrical - High Voltage Insulation and Electric Field

#### Mechanical Field Cage assembly



- HATPC in two half FCs
- Central cathode
- Special cathode flanges w/ HV ft
- Two End Plates (Al) supporting 8 Readout Modules each

#### Field Cage walls layout



### Field Cage walls layout



#### Electric field shaping by two Cu strips layers ('Field' and 'Mirror' strips)

0 mm



#### Double layer of strips on Kapton foil

Dimensions = 5m (inner surface cage perimeter) x 1m (drift distance) Resistors soldered on the inners surface (contact Mirror strips by vias) First ERAM pad @ 15mm from the wall where electric field uniformity better than 10<sup>-3</sup>

#### Field Cage mechanical details



-09.00

∕-Ø10.00

### Field Cage mechanical details

Labirinth

O-ring grooves

Flange

groove

Shield (Gnd)

Flange thickness (5cm) too small for degrading -30kV to GND over a flat surface

Three deep grooves for enhancing the path from HV to GND for charge moving on surface and with gas flanges ~ 7cm thick vs labirinth lenght ~ 14cm

 $\rightarrow$  voltage drop / path length < 3kV/cm



### Field Cage building, assembling and characterization

Production at NEXUS company (Barcelona) ~ 10 weeks Validation, QC, electrical and mechanical assembly at CERN ~ 4 weeks

#### Mold features

- 1cm thick Alu walls
- Anodyzd. Surfaces
- Waviness compl. iso1302 N8
- Surfaces ⊥ and ∥ better than 80µm/m
- Mount / unmount geom. reproducibility with high precision

### Field Cage building on a mould



#### Parts and materials

- Mold  $\rightarrow$  INFN
- Double layer strip foil  $\rightarrow$  CERN
- Structural parts = Flanges & Bars (G10  $\rightarrow$  ORVIM company (TV, Italy)
- Composite materials & Production → NEXUS company (Barcelona)

### Field Cage building, assembling and characterization

Production at NEXUS company (Barcelona) ~ 10 weeks Validation, QC, electrical and mechanical assembly at CERN ~ 4 weeks



•

5 m perimeter x 1m height (drift length)

Thick corners w/ Kapton tape

**Resin samples electrical Tests** 

Eletrical tests on surfaces

- Mold preparation
- Inner Vacuum bag
- Strip Foil positioning

Strip foil alignment and

lamination of 3 Kapton layers (125um each )



- Kapton lamination
- Curing at 40C
- Eletrical tests on surfaces
- and resin samples





- Kapton lamination
- Curing at 40C (fast = 12h) in autoclave
- Eletrical tests on surfaces and resin samples
- First Twaron layer lamination
- Curing at 40C (fast) in autoclave

#### Inner Twaron peel lamination and electrical insulation Quality Control

#### Resin Sample 10kV 177 173 FC#0 Internal Twaron layer

2

Resin sample (Resoltech Epoxy)

#### Quality controls – Resistivity of early Layers

1) Resistance between mold and 40x45cm2 electrode -> volume resistivity of layers



3) Resistance between two 6x80cm2 electrodes-> mix of surface and volume resistivity



 Surface resistivity of last layer Twaron





 various methods and electrode types (optimizing contact)
 → consistent measurements

2) Resin sample  $\rho_S \sim 10 \text{ T}\Omega/\Box$  $\rightarrow$  very good

# Gluing G10 "skeleton" Gluing G10 structural skeleton and casting resin on flanges for ensuring gas tightness G10 skeleton gluing Curing 40C in clean room Casting low viscosity resin on top flange (for sealing flange to laminated layers) ... in autoclave

Curing at 40C in autoclave

- Gluing Nomex Honeycomb
- Curing at 40C in owen



- Flipping the box top-bottom
- Resin casting on second flange
- Curing at 40C in autoclave
- Second Twaron peel lamination
- Curing at 40C in autoclave

- Post-curing at 40C in owen (lasting as long as possible)
- Post-process machining (removing aramid and resin in ecxess)
- Packaging and shipping to external company (Vallmoll Spain) for precision machining

#### Outer Twaron peel lamination



Back to NEXUS company for Mould removal Very fine polishing of flanges Correction of defects (eg bubbles)

precision machining of cathode and anode flanges

Precision machining of flages and finishing surfaces (polishing)



Shipment to CERN

100

#### Inner cage surfaces polishing





Checking grooves for o-ring and for charge labyrinth on cathode flanges



Measuring strip-strip and strip-shield insulation at high voltage

Mantle Resistance >  $2T\Omega$  ~ 2000 x voltage divider R

Looking for defects on strips and strip-strip short-circuits and repairing them

"field strips

"mirror strips "

2.549 2.55 2.54

Due to resistor selection, resistance values show rms retter than 10<sup>-4</sup> relative Soldering voltage divider resistors







Two voltage dividers in parallel ~400 resistors each => Overall  $R \sim 1G\Omega$ 

#### Vertical assembly of two Field Cages into HATPC



Cathode assembly





Cathode assembly



Connection of last strips to cathode and to high voltage feedtrough



High Voltage feedtrough external connection





High voltage tests after assembly



1) He leak tested w/ sniffer (air + 30mbar of He)

 $\Rightarrow$  Local Leaks < 10<sup>-4</sup> mbar L / s (considering filling He @ 1% partial pressure)

#### 2) Tested against gas density changes

- He Over-pressure (+20mbar)
- Air Under-pressure (-20mbar)

#### Several T, P, RH sensors Inside FC

BME280 – T<sub>cage</sub>, P, RH IR sensor - T<sub>gas</sub> Thermocouple and Pt100 Voltage divider current meas.



Gas density corrected for Volume variation (due to Pin - Pout) =  $\frac{Pin(t)}{Tin(t)/Tin(0)} \left(1 - \frac{\Delta V}{V0}\right)$  (Pin - Pout)



Gas leakeage qualification







Tolerances and specifications at a level better than 300µm/m for planes parallelism and ortogonality and better than ISO1302-N8 for waviness are respected with few localized acceptable exceptions



Metrology at CERN Bottom–HATPC (2023) (Two separate cages and cathode)

Measured internal geometry after assembly agrees with nominal within 300  $\mu m$  with few very localized and acceptable exceptions

#### Assembly 16 ERAMs in Clean room

Grey tent area in front of Clean Room large entrance for enhanced clean conditions



Commissioning at CERN with Cosmic Rays









Projection on Anode End Plate 1







3 old TPC + 1 HATPC

3 old TPC + 2 HATPC
#### Field Cage assembling, characterization at JPARC

Gas contamination from Field Cage – O2 and H2O



Drift velocity

Perfect agreement with expectations (Garfield++/Magboltz)

# **Highlights Field Cages**

Mechanical - Building, assembly and characterization



Electrical - High Voltage Insulation and Electric Field



Current drawn by voltage divider starting in large excess wrt nominal at power on and slowly decreasing to lower value but still in excess Current drawn by voltage divider starting in large excess wrt nominal at power on and slowly decreasing to lower value but still in excess



#### Insulation issue in full scale FC prototype

![](_page_39_Figure_1.jpeg)

#### Strip-Strip Potential difference of the strips @ 5kV

Voltage difference between Field strips (every 5 strips) ie  $V_1$ - $V_2$ ,  $V_5$ - $V_6$ ,  $V_{10}$ - $V_{11}$ , ...  $V_1$  = anode,  $V_{196}$  = cathode

![](_page_39_Figure_4.jpeg)

Measurement of Surface resistance of strip foil

(resistors removed)

15GIL

Resistance between single strips is very high  $O(T\Omega)$  ...but when joining some tens of strips to form a single

# Bad HV insulation among strips (without voltage divider)

Resistance is

- Independent of the distance between electrodes
- Linearly dependent of the number of the strips
- $\rightarrow$  not a surface resistance !

Measured R is rising with time (slow) up to saturation

- when repeating measurement, go faster to saturation
- when inverting polarity of electrodes, slow again
- $\rightarrow$  looks like due to dielectric polarization / relaxation
- $\rightarrow$  or capacitor charging trough high resistance

Find similar value of Resistance for same dimension electrodes formed in the Field Cage and on a strips foil when aluminum foil is placed underneath the foil  $\rightarrow$  next

# Buried resistive layer & electrical model

All observed features could be explained by the combination of two factors:

- 1) Presence of a resistive layer buried underneath the Kapton coverlay layer protecting the mirror Mirror strip
- 2) Low resistivity of the coverlay Kapton layer

![](_page_40_Figure_4.jpeg)

### **Buried resistive layer**

In fact we **verified** the following

1) Coverlay Kapton volume resistivity was O(1GΩcm) (much lower than datasheet)

coverlay

Resin

Kapton 25µm

impregnated Twaron layer

2) Twaron layer facing the coverlay featured surface resistivity  $O(1G\Omega/\Box)$ 

#### Sources of "resistive" contamination

Both features could on turn be explained by the accidental use of antistatic spray (resistive) on the back of the strip foil (ie on the coverlay) after the strip foild was fixed on the mould, in order to keep the huge foil surface (5m2) clean from dust and other possible contaminants. The spray contaminated both the Kapton coverlay (being very easily adsorbed) and the innermost layer of the Twaron (being mixed with the resin which impregnates the fiber fabric, during the Twaron lamination phase)

We could not exclude alternative sources of contamination affecting the resin and making it resistive (eg presence of water if epoxy not treated in vacuum after mixing)

# Buried resistive layer $\rightarrow$ electrical model

![](_page_42_Figure_1.jpeg)

After appluing HV after applying HV (eg -10kV) to the cathode, two phases:

1) **Transient state**: in time scale depending of the contaminated layers resistivity (in our case very short O(10s) time scale) the buried resistive layer become equipotential (setting at intermediate potential -5kV) by drawing charge from the strips

2) **Steady state:**Mirror strips on the Anode half convery current to the buried layer, while mirror strips on the Cathode side draw currents from the buried layer

### Buried resistive layer $\rightarrow$ electrical model

![](_page_43_Figure_1.jpeg)

### Buried resistive layer & electrical model

![](_page_44_Figure_1.jpeg)

### Buried resistive layer & electrical model

![](_page_45_Figure_1.jpeg)

In addition, the coverlay Kapton layer may undergo dielectric breakdown especially in the Anode and Cathode regions (large potential gap wrt buried layer)

![](_page_45_Figure_3.jpeg)

# => Final layout, materials and procedures fixed for the HATPC F.Cages production

#### Key points to avoid failures

- no resin contamination !!! Note: usually glues and resins are the weakest points

- Interpose between strips and Twaron layers a "thick" layer of insulator featuring
  - High resistivity  $\rho_v > 10^{15} \Omega cm$
  - Dielectric strength > 150kV/mm

#### Final layout of the stack: minimal changes to design

- new strip foil w/ thicker Kapton coverlay 50µm + 25µm glue (produced at CERN, gluing in vacuum with press)
- 3 layers of Kapton: 125μm + 50μm resin each (to be laminated on the back of strip foil on the mold)

 $\rightarrow$  thickness Kapton+Resin ~0.5mm  $\rightarrow$  "vertical R" below 1 strip O(10T $\Omega$ ) @ 10kV

#### Materials: Same insulating materials (Kapton + Aramide) and same resin (Resoltech)

#### Production procedure and enhanced QC

- Minimize moisture trapped in wall layers: drying in owen Kapton & Twaron just before use
- QC epoxy contaminaiton -> proper control of mixing and de-gasing process (new mixing / degassing tools and QC) and ... avoid antistatic spray...
- QC electrical resistivity measurements after each early step in the production

![](_page_46_Figure_15.jpeg)

# Highlights ERAMs

Production of 50 detectors and Operations experiences

Detector response, signal and impact on reconstruction

# Charge readout – MicroMegas w/ resistive foil

#### Resistive layer enables Charge spreading

- $\rightarrow$  space resolution below 500  $\mu m$  with larger pads
- $\rightarrow$  less FEE channels (lower cost)
- $\rightarrow$  improved resolution at small drift distance (where transverse diffusion cannot help)

#### Resistive layer prevents charge build-up and hides sparks

- $\rightarrow$  enables operation at higher gain
- $\rightarrow$  no need for spark protection circuits for ASICs
  - $\rightarrow$  compact FEE  $\rightarrow$  max active volume

#### **Resistive layer encapsulated** and properly insulated from GND

- $\rightarrow$  Mesh at ground and Resistive layer at +HV
- $\rightarrow$  improved field homogeneity  $\rightarrow$  reduced track distortions
- $\rightarrow$  better shielding from mesh and DLC  $\rightarrow$  potentially better S/N

![](_page_48_Figure_13.jpeg)

![](_page_48_Figure_14.jpeg)

![](_page_48_Figure_15.jpeg)

#### **ERAM module**

#### 8 + 8 ERAMs per HATPC

![](_page_49_Figure_2.jpeg)

36x32=1152 pads : 2 x 576 ch. FEC + 1 FEM2 + 1 PDC

# Charge spread on low resistivity foil

#### Charge Spreading 2D telegraph eqn. solution in O(RC) time scale

R- surface resistivity

C- capacitance/unit area

Gaussian spread

 $\frac{\partial \rho}{\partial t} = h \left[ \frac{\partial^2 \rho}{\partial r^2} + \frac{1}{r} \frac{\partial \rho}{\partial r} \right] \implies \rho(r, t) = \frac{RC}{2t} e^{-r^2 RC/(4t)}$   $\sigma_r = \sqrt{\frac{2t}{RC}} \begin{cases} t \approx shaping time (few 100 ns) \\ RC_{[ns/mm^2]} = \frac{180 R_{[M\Omega/\bullet]}}{d_{[\mu m]}/_{175}} \end{cases}$ 

![](_page_50_Figure_6.jpeg)

![](_page_50_Figure_7.jpeg)

Final ERAM layout choice for series production:

Considering pads of 11x10 mm<sup>2</sup> parameters

- 400 k $\Omega$ / $\Box$  DLC resistivity low resistivity
- 150  $\mu$ m thickness glue C<sub>dlc-pad/gnd</sub> ~ O(20pF)

 $\Rightarrow$  RC ~ O(100ns/mm<sup>2</sup>)

Trade-off optimal charge spread VS spark protection ... and stability of operations

Gain not affected by resistivity (transparency to induced signals guaranteed)

#### **ERAM Production - about 50 detectors**

Crucial steps in production (CERN MPGD worksohp)

- 1) Selecting DLC foil resistivity
- Large variations from DLC provider
- Value fixed & stabilized w/ annealing
- 2) Gluing steps by Pressing
- DLC to PCB
- Stiffener to DLC-PCB

X-rays Test Bench (CERN, our laboratory hall)

1) Qualify, characterize and calibrate all prototypes and series ERAMs

2) Crucial for developing detailed ERAM response model

![](_page_51_Figure_11.jpeg)

#### **ERAM Series Production experience**

![](_page_52_Figure_1.jpeg)

Mesh pulsing : before and after stiffener gluing Aim: detector geom, R, C, defects (eg pillars detachm.), gluing issues, electronic noise

X-ray scan of finalized detectors with final electronic modules Remote controlled station for scannig with mm step fine steps Aim: QC and fine calibration in terms of gain, resolution and RC

X-rays Test Bench at CERN was fundamental to

1) Qualify, characterize and calibrate all prototypes and series ERAMs

2) support the development of detailed ERAM response model

![](_page_52_Figure_8.jpeg)

#### **ERAM Series Production experience**

![](_page_53_Figure_1.jpeg)

 $1\mu m$  mesh-DLC gap variation => 10% variation in gain

#### **ERAM Series Production experience**

![](_page_54_Figure_1.jpeg)

#### **ERAM Assembly and Operation experience**

Low resistivity DLC O(500k $\Omega/\Box$ ) [after annealing] features

- Optimal charge spread → uniform response across pad (combined with C ~ O(20pF/cm<sup>2</sup>)
- Fast Q removal and Effective Protection agains sparks included at moderate rates ~ O(1kHz) tracks crossin pads
- Leakage currents at level of few nA in normal conditions (no beam)

#### Annoying aspects

- $\rightarrow$  high sensitivity to dust
- $\rightarrow$  low H2O level (100ppm) before HV on

![](_page_55_Figure_8.jpeg)

![](_page_55_Picture_9.jpeg)

![](_page_55_Picture_10.jpeg)

Grey tent area in front of Clean Room arge entrance for enhanced clean conditions

![](_page_55_Picture_12.jpeg)

![](_page_55_Picture_13.jpeg)

# Highlights ERAMs

Production of 50 detectors and Operations experiences

![](_page_56_Picture_2.jpeg)

#### **ERAM detector response – Signal formation** How does the signal look ? point deposition for example

![](_page_57_Figure_1.jpeg)

ADC signal : max 4096 counts Time window of 511 time bins Time bin (typ.): 40 ns (25 MHz sampling)

Leading pad: highest and earliest signal  $\Rightarrow$  current induced on pads from by avalanche, ie **<u>ions</u>** signal (as electrons' signal is too fast)

Adjacent pads: lower and later signals  $\Rightarrow$  current induced by potential field adjustments after <u>electrons</u> are collected by on DLC (current induction by "charge spread on resistive layer")

### Reconstruction of charge deposition

![](_page_58_Figure_1.jpeg)

![](_page_58_Picture_2.jpeg)

Recovering information about deposited Q is not trivial

Within our electronics shaping time scale

in primary pads, the <u>signal of ions</u> is <u>«diluted»</u> by the <u>signal of charge spreading</u> => Need combinig information of all pads (primary and secondary)

### Reconstruction of charge deposition

![](_page_59_Figure_1.jpeg)

### ERAM response – Signal formation model

#### Main ingredients

![](_page_60_Figure_2.jpeg)

0.004

Vc = -350, Va = 460

w<sub>s</sub>~1/Peaking time and Q quality factor

#### **ERAM detector response – Reconstruction**

#### Model for Reconstructing amount and position of Q deposition

Due to square shape of ERAM pads, the classical method (PRF+clustering) works OK only for tracks with horizontal or vertical direction (wrt pads coordinates)

Better methods use solutions of 1D or 2D telegraph equation in order to

- 1) diffuse template patterns charge on DLC
- 2) calculate the overall expected signal waveform per each pad and
- 3) find the best matching with the recorded waveforms

Its computationally heavy => different approximations are used for different analysis some examples  $\rightarrow$  illustration algorithoms and TPC performances Eg: X-rays analysis for ERAM characterization

### **Reconstructing x-rays**

Qpad(t) = Solution of 2D Teq. for diffusion of initial Qe deposited charge (point-like, delta-pulse initial conditions)

$$Q_{pad}(t) = \frac{Q_e}{4} \times \left[ erf(\frac{x_{\mathsf{high}} - x_0}{\sqrt{2}\sigma(t)}) - erf(\frac{x_{\mathsf{low}} - x_0}{\sqrt{2}\sigma(t)}) \right] \times \left[ erf(\frac{y_{\mathsf{high}} - y_0}{\sqrt{2}\sigma(t)}) - erf(\frac{y_{\mathsf{low}} - y_0}{\sqrt{2}\sigma(t)}) \right]$$

- ⇒ Obtained from Telegrapher's equation for charge diffusion.
- Integrating charge density function over area of 1 readout pad.
- Parameterized by 5 variables:
  - $x_0$  Initial charge position
  - t<sub>o</sub>: Time of charge deposition in leading pad
  - RC : Describes charge spreading
  - Q<sub>e</sub>: Total charge deposited in an event

 $x_{\mu}$ ,  $x_{L}$ : Upper and lower bound of a pad in x-direction  $y_{\mu}$ ,  $y_{L}$ : Upper and lower bound of a pad in y-direction

![](_page_62_Figure_11.jpeg)

![](_page_62_Figure_12.jpeg)

### **Reconstructing x-rays**

Current induced on a pad dQpad(t) / dt to be convoluted with electronics transfer function R(t)  $dQ/dt \otimes R(t) = Q(t) \otimes dR(t)/dt$  $Q(t) \otimes dR(t)/dt$  is more practical

#### WF templates

![](_page_63_Figure_3.jpeg)

Simultaneous fit of waveforms of Leading pad + Neighbouring pads to get the best 5 parameters

![](_page_63_Figure_5.jpeg)

WF fit against templates

![](_page_63_Figure_7.jpeg)

![](_page_63_Figure_8.jpeg)

![](_page_63_Figure_9.jpeg)

#### x-rays → RC & Gain maps

Use for calibrartion of top and bottom HATPC ERAM GAIN

![](_page_64_Figure_2.jpeg)

X-ray conversion position is also fitted => accurate maps of Gain and RC

Use for detailed stiudies of charge diffusion and ERAM response at fine PAD position level

![](_page_64_Figure_5.jpeg)

the **better performances** (eg space resolution)

#### Space and dE/dx resolution

![](_page_65_Figure_1.jpeg)

### **PID** preliminary results

 $e/\mu$  separation @ 1.5 GeV – Test Beam data (CERN PS T10)

![](_page_66_Figure_2.jpeg)

Long tracks (~160cm)

![](_page_66_Figure_4.jpeg)

•  $\mu^+$  & e<sup>+</sup> split by more than  $6\sigma$ 

# Conclusions

#### Two new TPCs have been recently installed in ND280 at JPARC

- Very stable operations in commissioning and neutrino beam runs

#### Field cages

- High ratio active/passive volume
- Highly effective insulation & E field uniformity

#### Resistive MM with encapsulated anode

- Low resistivity & optimal charge spread & no sparks effects
- Series production allowed several detailed studies
- New algorithms for square pads exploiting detailed response model

### **Additional Material**

# **Top-HATPC** installed end April 2024

![](_page_69_Picture_1.jpeg)

![](_page_69_Picture_2.jpeg)

Lowering bottom HATPC 2023.9.8

Top - HATPC in ND280

![](_page_69_Picture_5.jpeg)

![](_page_69_Picture_6.jpeg)

Bottom - HATPC in ND280

![](_page_69_Picture_8.jpeg)

Bottom - HATPC

ND280 after lowering of top HATPC 2024.4.25

![](_page_69_Picture_10.jpeg)

#### ND280 fully upgraded detector ready in May

#### **Buried resistive layer: electrical model results**

![](_page_70_Figure_1.jpeg)

#### **Buried resistive layer: fit to the data**

![](_page_71_Figure_1.jpeg)
### HATPC studies and calibration plan -- CERN

1) Recover FC0 and setup a new half HATPC at CERN => TPC0

- ✓ Removed corrupted strip foil and recovered corrupted inner surfaces
- ✓ Replacing strip foil with new one => September 2024



### Reconstructing Q along tracks $\rightarrow$ dE/dx



#### Reconstructing Q along tracks $\rightarrow$ dE/dx

Method of «crossed Pads» (XP)

- 1) Reconstruct tracks and consider only pads crossed (XP) by the track (primary pads)
- 2) Reconstruct original (ion induced) charge (Q) for each XP (given the track parameters there)
- by  $Q = A \times (Q/A)$  where A is recorded amplitude on XP and rescaling ratio (Q/A) from Look Up tables (LUT)
- LUTs build from model: original Q is distrubuted linearly over the segment for each XP so that solutions of 1D diffusion equations can be used



No clustering => potentially more accurate method because reconstructing full induced charge on primary pads
«dilution of ion signal» on a XP pad, due to charge spread over the pad is correctly taken into account
«longitudinal correlation» among adjacent XP pads, due to charge spread along track direnction, accounted for
Fast method though based on model templates (long time is to generate LUTs ...)

#### Reconstructing Q along tracks $\rightarrow$ dE/dx

Building the rescaling ratio Q/A ratio 4D LUTs via model

4D Look-Up Table (LUT):

- Angle φ: 200 steps [0°, 90°]
- Impact parameter: 200 steps [-7.3, +7.3] mm
- Drift distance: 21 steps [0, 1] m
- RC: 21 steps [50, 150] ns/mm<sup>2</sup>



#### dE/dx preliminary results

dE/dx (4GeV electrons) – comparison of SWF and XP methods on Test Beam data (DESY)



XP gives better results at diagonal angle

 Slight sink with WF<sub>sum</sub> for diagonal clusters (compensated by correction function)

#### dE/dx preliminary results

dE/dx (160cm long tracks) – XP method on Test Beam data (CERN PS T10)



### **PID** preliminary results

 $e/\mu$  separation @ 1.5 GeV – Test Beam data (CERN PS T10)



Long tracks (~160cm)



•  $\mu^+$  & e<sup>+</sup> split by more than  $6\sigma$ 

### Reconstructing tracks – trajectory fitting

LogQ Method based on clustering & Log[Qprimary /Qsecondary]

- logQ method to reconstruct position in each cluster
- Helix fit performed on those reconstructed positions

Full Waveform fit Method – based on model & no clustering

1) Use all the pads associated to a track (Qmax values) to define a (v,u) local frame

2) Distribute "arbitrary" point charges along v axis separated by  $\Delta v$  (5mm) Q per each point is a free parameter

3) diffusion model to predict the waveform generated by point charges in surrounding pads

4) Move all points along the u axis to minimize the chi-square difference between measured waveforms and templates using RungeKutta method to fit (u0, du/dv, q/p, t0, dt/dv)



 $dx = f(\log(Q_1/Q_0) \text{ or } \log(Q_2/Q_1))$ 

#### Reconstructing tracks – momentum resolution

 $\sigma_{o}$ /p Momentum resolution as a function of track drift distance -- simulated 700 MeV/c muons



## Near Detector impact on Oscillation Analysis

- ND280 magnetized detector
- Select interactions in FGD and measure muon kinematics in the TPCs
- Separate samples based on number of reconstructed pions (CC0π, CC1π, CCNπ), protons, photons, etc
- Factor of ~3 reduction on the uncertainty on the event rates at the Far Detector



	Pre- ND FIT	Post- ND FIT
Sample	error	error
FHC $1R\mu$	11.1%	3.0%
RHC $1R\mu$	11.3%	4.0%
FHC 1Re	13.0%	4.7 %
RHC 1Re	12.1%	5.9%
FHC 1Re 1d.e.	18.7%	14.3%



# ND280 limitations



- Improve angular acceptance  $\nu$
- · Better reconstruction and usage of the hadronic part of the interactions!
  - Currently samples are selected according to their topology (0π, 1π, 1p, Nπ, ...) but the kinematics of the hadrons is not used in any way in the constraint on flux and x-sec systematics → plenty of additional information to be exploited
  - This is due to both, a low efficiency from ND280 to reconstruct hadrons and the difficulties in modeling the x-sec systematics for the hadronic part
    - With the upgrade we plan to improve the efficiency to reconstruct hadronic part



# ND280 Upgrade improvements



- A SFGD reconstructed track
- High-Angle TPCs allow to reconstruct muons at any angle with respect to beam
- Super-FGD allow to fully reconstruct in 3D the tracks issued by v interactions →lower threshold and excellent resolution to reconstruct protons at any angle
  - Improved PID performances thanks to the high granularity and light yield
- Neutrons will also be reconstructed by using time of flight between vertex of v
  interaction and the neutron re-interaction in the detector



Protons → threshold down to 300 MeV/c



## Mantle resistance



Figura 4.2: Spostamento lungo R del punto di arrivo di un elettrone causato da una resistenza R<sub>man</sub> di un mantello isolante mille volte il valore della catena di resistori R. La distorsione é mostrata come funzione del punto di partenza z (Distanza dall'anodo).

#### **ERAM Production - about 50 detectors**

**Crucial steps in production** (needed tuning)

- 1) Selecting DLC foil resistivity
- Large variations from DLC provider
- Value stable after annealing
- 2) Gluing steps by Pressing
- DLC to PCB
- Stiffener to DLC-PCB

X-rays Test Bench at CERN was fundamental to

1) Qualify, characterize and calibrate all prototypes and series ERAMs

2) support the development of detailed ERAM response model



#### Field Cage assembling, characterization at CERN

Gas contamination from Field Cage – other contaminants



No HF acid a parently (below Ar++)

Analysis of gas composition during cosmics test in May



• Evolution in time of components

#### **ERAM Series Production experience**

Ypad

20

15

#### Effect of gas density on (gas) GAIN





Effect of humidity on (gas) GAIN



#### **ERAM detector response – Simulation**

Use of the model for Simulation of charge deposition in events Where additoinal ingredient is noise detailed modeled



#### Reconstructing tracks dE/dx

dE/dx – comparison of SWF and XP methods on Test Beam data (4GeV electrons, DESY)



- Very good agreement overall
- Better resolution with XP with diagonal tracks



- Disagreement at small drift distance: reflects the track fitting quality
- Disagreement for Y scan: taken at small drift distance
- Disagreement for diagonal tracks: using only on correction function for WF<sub>sum</sub> is not suitable

#### Reconstructing tracks – pattern recognition



- Time and charge definition for each hit
- Waveform multipeak search in order to differentiate vertices and crossing trajectories
- Merging between different ERAMs and End Plates



#### Reconstructing tracks – trajectory fitting



# T2K gas properties



T2K gas

# The ND280 Upgrade

#### The SuperFGD for T2K → See talk by Tristan Doyle



arXiv:1901.03750

France (CEA Saclay, LLR, LPNHE), Germany (RWTH), Italy (INFN Sezioni di Bari, Napoli, Legnaro, Padova, Roma 1), Poland (IFJ Pan, NCBJ, WUT), Russia (INR and Dubna), Spain (IFAE), Switzerland (University of Geneva, ETHZ) + CERN

Japan: University of Tokyo, KEK, Kyoto University, Tokyo Metropolitan University

USA: Louisiana State University, University of Colorado, University of Pennsylvania, University of Pittsburgh, Stony Brook University, University of Rochester

MoU signed in 2020 → NP-07

#### New detectors to extend acceptance for tracks at high angles